Abstract Submitted for the GEC09 Meeting of The American Physical Society

Parabolic Cross-Sectional  $Al_2O_3$  Microcavity Devices: Volume Dependent Plasma Characteristics Optimization JE KWON YOON<sup>1</sup>, BRIAN P. CHUNG<sup>2</sup>, YEON JOON MOON<sup>3</sup>, SUNG-JIN PARK<sup>4</sup>, J. GARY EDEN<sup>5</sup>, University of Illinois at Urbana-Champaign — Parabolic cross-sectional microcavity arrays having as small as 80  $\mu$ m apertures have been reported [1]. As an electrode, ~100  $\mu$ m thick aluminum foil is used and wet chemical processes can reduce the thickness of the electrode as thin as  $20\mu$ m, varying the volume of the plasma. Due to the controllable electrode height and the electrochemical method introduced previously, dynamic range of aspect ratio from 0.2 to 2.2 can be provided. Plasma volumes from 1.3 to 6.9 pm<sup>3</sup> are evaluated while the diameters of apertures are kept constant. Plasma characteristics such as Paschen's curve and emission spectrums in Ne and Ne/Xe are investigated below 700 torr. This study can be applied to devices for display.

[1] K. S. Kim, T. L. Kim, J. K. Yoon, S.-J. Park, and J. G. Eden, Appl. Phys. Lett., 94, 011503, 2009.

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Date submitted: 15 Jun 2009

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